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| <b>Search Notes</b><br><br> | <b>Application/Control No.</b><br><br>10758828 | <b>Applicant(s)/Patent Under Reexamination</b><br><br>LEMAY ET AL. |
|  | <b>Examiner</b><br><br>Lee, Benjamin W         | <b>Art Unit</b><br><br>3709  |

| SEARCHED |            |           |          |
|----------|------------|-----------|----------|
| Class    | Subclass   | Date      | Examiner |
| 463      | 24, 29, 34 | 12-7-2006 | BWL      |
| 345      | 547-549    | 12-7-2006 | BWL      |

| SEARCH NOTES                                     |           |          |
|--|-----------|----------|
| Search Notes                                     | Date      | Examiner |
| Inventor Name Search                             | 12-7-2006 | BWL      |
| Assignee Search                                  | 12-7-2006 | BWL      |
| Consulted with Kim Nguyen, Cls. 463, 345         | 12-5-2006 | BWL      |
| PLUS Search                                      | 12-4-2006 | BWL      |
| East Text Search (see attached "Search History") | 12-8-2006 | BWL      |
| Backward/Forward Search                          | 12-8-2006 | BWL      |

| INTERFERENCE SEARCH |          |      |          |
|---------------------|----------|------|----------|
| Class               | Subclass | Date | Examiner |
|                     |          |      |          |